

Malaviya National Institute of Technology Jaipur

Materials Research Centre

The following are the charges for testing sample at MRC, MNIT Jaipur

| S. No. | Equipment | | MNIT Jaipur Charges (GST applicable extra as per rules) | | |
|---|---|------------------------|---|--|---|
| | | | Internal Users | External (Academic) | External (Industries) |
| 1. | <u>NMR</u> A. For Proton (1H) | | 250 per sample + *Solvent Charges Extra | 500 per sample + *Solvent Charges Extra | 1000 per sample + *Solvent Charges Extra |
| | B. C ¹³ & DEPT | | 300 per sample + *Solvent Charges Extra | 600 per sample + *Solvent Charges Extra | 1200 per sample + *Solvent Charges Extra |
| | C. For Other Nuclei (¹⁹ F, Si, P, N, Cd, Metal, F & Sn etc) | | 500 per sample + *Solvent Charges Extra | 800 per sample + *Solvent Charges Extra | 1000 per sample + *Solvent Charges Extra |
| | D. Other than 1D for 2D & 3D Additional charges of Rs. 500 per sample on per mode is applicable. | | 800 per sample + *Solvent Charges Extra | 1200 per sample + *Solvent Charges Extra | 2000 per sample + *Solvent Charges Extra |
| *Solvent charges for NMR: 1. Rs. 100/sample - CDCl ₃ , 2. Rs. 250/ sample - DMSO, 3. Rs. 250/sample - D ₂ O, 4. Rs. 500/sample - CD ₃ OD, 5. Rs. 500/sample - CD ₃ CN | | | | | |
| 2. | <u>Mass Spectrometer</u> <u>For direct mass and MS/MS*</u> a. ESI (Charges will be separate for + ^{ve} and - ^{ve} mode) | | 300 per sample with solvent | 600 per sample with solvent | 1000 per sample with solvent |
| | b. APCI | | 300 per sample with solvent | 600 per sample with solvent | 1000 per sample with solvent |
| | c. Solid State Probe Mode | | 400 per sample | 1200 per sample | 2400 per sample |
| | d. LCMS (per run) | | 600 per sample with solvent | 1200 per sample with solvent | 1500 per sample with solvent |
| 3. | FTIR (KBr Mode) | | 75 per sample (max. 16 scan) | 125 per sample (max. 16 scan) | 300 per sample (max. 16 scan) |
| | FTIR (ATR Mode) | | 50 per sample (max. 16 scan) | 100 per sample (max. 16 scan) | 300 per sample (max. 16 scan) |
| 4. | <u>UV-Vis Spectrophotometer</u> | | 50 per sample & per run | 100 per sample & per run | 300 per sample & per run |
| 5. | Fluorescence Spectrophotometer | | 50 per sample & per run | 75 per sample & per run | 400 per sample & per run |
| 6. | XRD (Max. 2 samples/hour) | Powder or Solid Sample | 300 per sample | 500 per sample | 800 per sample |
| | | Thin Film | 350 per sample | 600 per sample | 1200 per sample |

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| 7. | FE-SEM | FESEM (Imaging) | 350 per sample | 700 per sample | 2000 per sample |
| | | FESEM + EDS | 450 per sample | 900 per sample | 2200 per sample |
| | | FESEM + EDS + Mapping | 550 per sample | 1200 per sample | 2400 per sample |
| | | EBSD | 1500/ Sample (Excluding Sample Preparation) | 2650/ Sample (Excluding Sample Preparation) | 12000/ Sample (Excluding Sample Preparation) |
| | Sputter Coater | Au, Pt coating | 350/Run (5 sample) | 400/Run (Max 5 samples) | 500/Run (Max 5 samples) |
| | | Carbon Evaporator | 300/Run (Max 5 sample) | 300/Run (Max 5 samples) | 300/Run (Max 5 samples) |
| 8. | HR-TEM | HRTEM (Max 1 sample / hour) | 500/sample+ 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 1500/sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 3000/Sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user |
| | | HRTEM + EDS (Max 1 sample / hour) | 600/sample+ 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 1750/sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 3200/Sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user |
| | | HRTEM + EDS + MAPPING | 800/sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 2000/sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user | 3500/Sample + 600 (Ion Milling if needed) Cu-Grid - Rs. 350 Extra if not provided by user |
| 9. | Multimode AFM | AFM (Max. 2 samples/hour) | 400 per sample | 600 per sample | 1500 per sample |
| | | MFM or STM | 1200 per Sample | 2200 per Sample | 5000 per Sample |
| | | Nano indentation | 1500 per sample | 3500 per sample | 7200 per sample |
| 10. | DMA | | 500 per hour | 800 per hour | 1500 per hour |
| 11. | STA/TGA | | 400 per hour | 600 per hour | 2000 per hour |
| 12. | OES/GDS | | 160 per Sample | 300 per Sample | 800 per Sample |
| 13. | AAS (For As & Hg) | | 400 per sample | 500 per sample | 1000 per sample |
| | AAS (Other elements) | | 200 per sample | 300 per sample | 1000 per sample |
| 14. | Thermal CVD | | 800 per run | 1800 per run | 3500 per run |
| 15. | Vacuum Coating Unit | | 800 per run Thickness limit 500nm | 1800 per run Thickness limit 500nm | 3500 per run Thickness limit 500nm |
| 16. | RF/DC Sputtering (For Oxides) | | 800 per run Thickness limit 200nm | 1800 per run Thickness limit 200nm | 3500 per run Thickness limit 200nm |

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| | RF/DC Sputtering (For Metals) | 800 per run Thickness limit 500nm | 1800 per run Thickness limit 500nm | 3500 per run Thickness limit 500nm | |
| 17 | Available Targets | 1. ZnO (99.99% purity) | 500 Thickness limit 200nm | 800 Thickness limit 200nm | 2000 Thickness limit 200nm |
| | | 2. TiO ₂ (99.99% purity) | 500 Thickness limit 200nm | 800 Thickness limit 200nm | 2000 Thickness limit 200nm |
| | | 3. Al (99.99% purity) | 500 Thickness limit 500nm | 800 Thickness limit 500nm | 2000 Thickness limit 500nm |
| | | 5. Zn (99.99% purity) | 500 Thickness limit 500nm | 800 Thickness limit 500nm | 2000 Thickness limit 500nm |
| | | 6. Cu (99.99% purity) | 500 Thickness limit 500nm | 800 Thickness limit 500nm | 2000 Thickness limit 500nm |
| | | 7. Silver (99.99% purity) | 600 Thickness limit 100nm | 1000 Thickness limit 100nm | 2500 Thickness limit 100nm |
| 18. | Planetary Ball Milling | 100 per hour | 250 per hour | 500 per hour | |
| 19. | Microwave Reactor | 100 per Reaction | 300 per Reaction | 800 per Reaction | |
| 20. | Spin Coater | 50 per Run | 200 per Run | 500 per Run | |
| 21. | <u>XPS</u> (i) Surface Survey (C + 4 Elements HR scan included) | 1000/Sample 100 for extra per element HR scan | 2000/Sample 200 for extra per element HR scan | 3000/Sample 400 for extra per element HR scan | |
| | (ii) Depth Profile (Max 5 hrs) | 1500/Sample | 3000/Sample | 5500/Sample | |
| | (iii) UPS | 1500/ Sample | 3000/ Sample | 5500/ Sample | |
| | (iv) AES | 600/ Sample | 1500/ Sample | 2000/ Sample | |
| | (v) Heating (>RT) up to 400 ⁰ C | 200/ for one specific Temp. | 200/ for one specific Temp. | 200/ for one specific Temp. | |
| 22. | Raman / PL | 300/ Sample | 450/ Sample | 1000/ Sample | |
| | Raman Mapping | 12000 per hour (apprx 100 points) | 12000 per hour (apprx 100 points) | 25000 per hour (apprx 100 points) | |
| Characterization at different temperatures (-150 degree centigrade to 200 degree centigrade) will be treated as different sample and charges will be applicable accordingly. For temperature stage solid sample size is limited to L x B x H = 1cm x 1cm x 1mm. | | | | | |
| 23. | Zeta Potential / Particle Size Analyzer | 110/ Sample | 175/ Sample | 500/ Sample | |
| 24. | Impedance Analyzer | 125/ Sample | 150/ Sample | 1000/ Sample | |
| 25. | SDA + Probe Station (I-V) | 150/ Sample at Room Temp. (And 450 per hr. Will be charge for Temp. | 285/ Sample at Room Temp. (And 725 per hr. Will be charge for Temp. | 1000/ Sample at Room Temp. (And 2000 per hr. Will be charge for Temp. | |

| | | Variation measurement) | Variation measurement) | Variation measurement) | |
|-----|---|--|--|--|----------------|
| 26. | Micro Hardness Tester | 100/ Sample | 250/ Sample | 500/ Sample | |
| 27. | Optical Microscope | 100/sample | 200/sample | 500/sample | |
| 28. | Hall Measurement | 150 per sample (And 300/hour for Temp. Variable measurement) | 250/ sample (And 600/hour for Temp. Variable measurement). | 1000/sample (And 2000/hour for Temp. Variable measurement) | |
| 29. | UTM (Universal Testing Machine) | 200 per sample | 500 per sample | 1000 per sample | |
| 30. | DI Water | 10 per liter | 10 per liter | 10 per liter | |
| 31. | LN ₂ | 50 per liter | 50 per liter | 50 per liter | |
| 32. | Sample Preparation Facility | Abrasive Cutter Or Diamond Cutter | 100 per sample | 100 per sample | 100 per sample |
| | | Hot mounting press | 100 per sample | 100 per sample | 100 per sample |
| | | Automatic Polisher or manual Polisher | 100 per sample | 100 per sample | 100 per sample |
| | | PIPS ion Milling for TEM | 600 per sample | 600 per sample | 600 per sample |
| | | Electro jet Polishing For TEM | 600 per sample | 600 per sample | 600 per sample |
| | | X-Section sample Prep for TEM | 600 per sample | 600 per sample | 600 per sample |
| | | Illion X-section sample Prep for FESEM | 600 per sample | 600 per sample | 600 per sample |
| | | EBSM sample Prep. | 600 per sample | 600 per sample | 600 per sample |
| | | Sonicator Bath or probe | -- | -- | -- |
| 33 | Electro Chemical Work Station | 500 per test | 1000 per test | 2000 per test | |
| 34 | BET Surface Area Analyser (Multi Point) | 1500 per sample | 2000 per sample | 3000 per sample | |